

The Effect of Fast Electron Scattering in Determining the Laser-Induced Electron Divergence

S. Jiang

The Ohio State University

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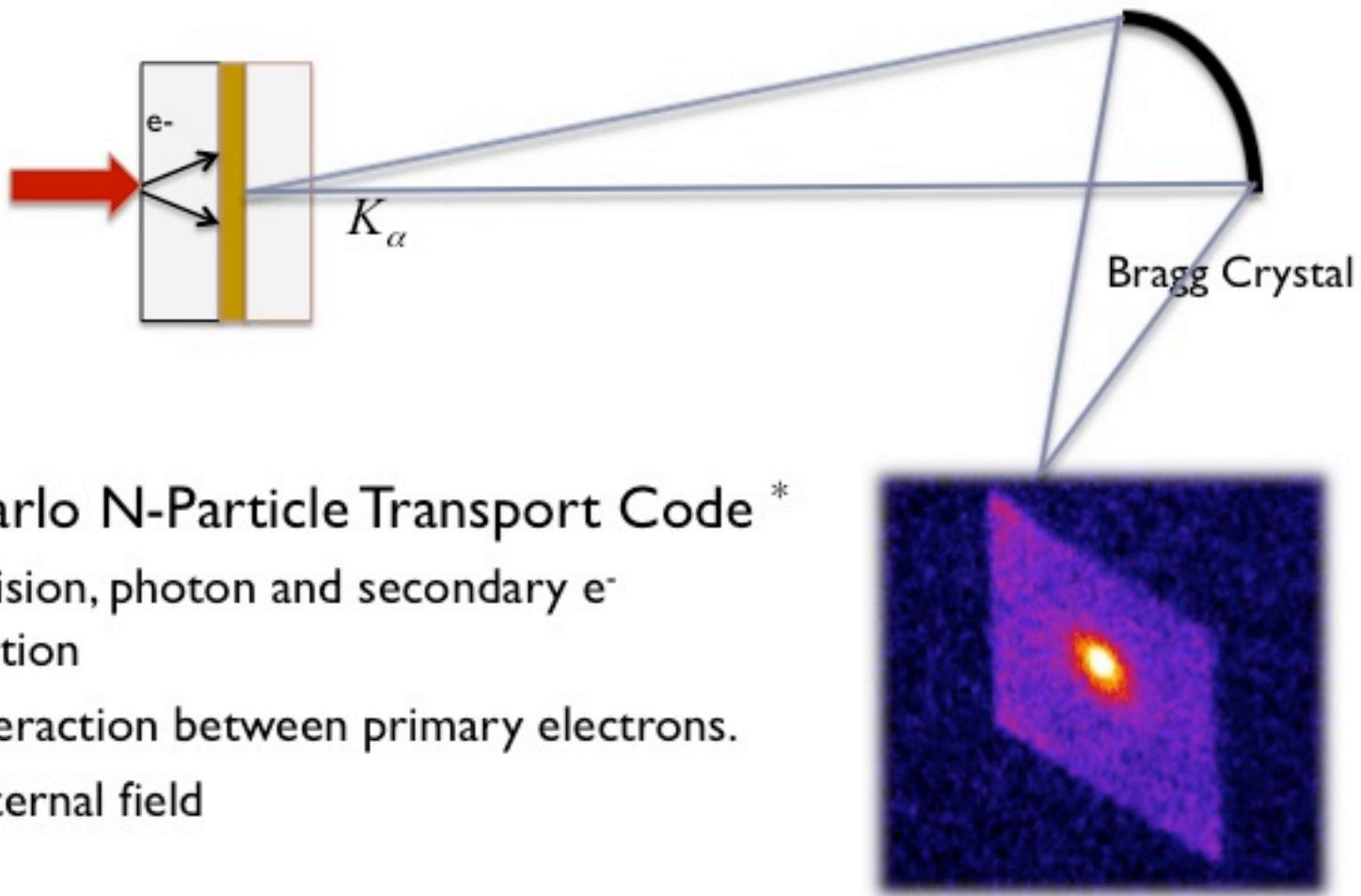
High Energy Density Physics Group
Scarlet Laser Facility



Outline

- ▶ Scattering effect in low Z and high Z materials
- ▶ Effect of the source size on beam divergence
- ▶ Comparison of mono-energetic and Maxwell energy distributions
- ▶ Beam divergence using a laser based electron source
- ▶ Conclusions

Motivation and Method



► Monte Carlo N-Particle Transport Code *

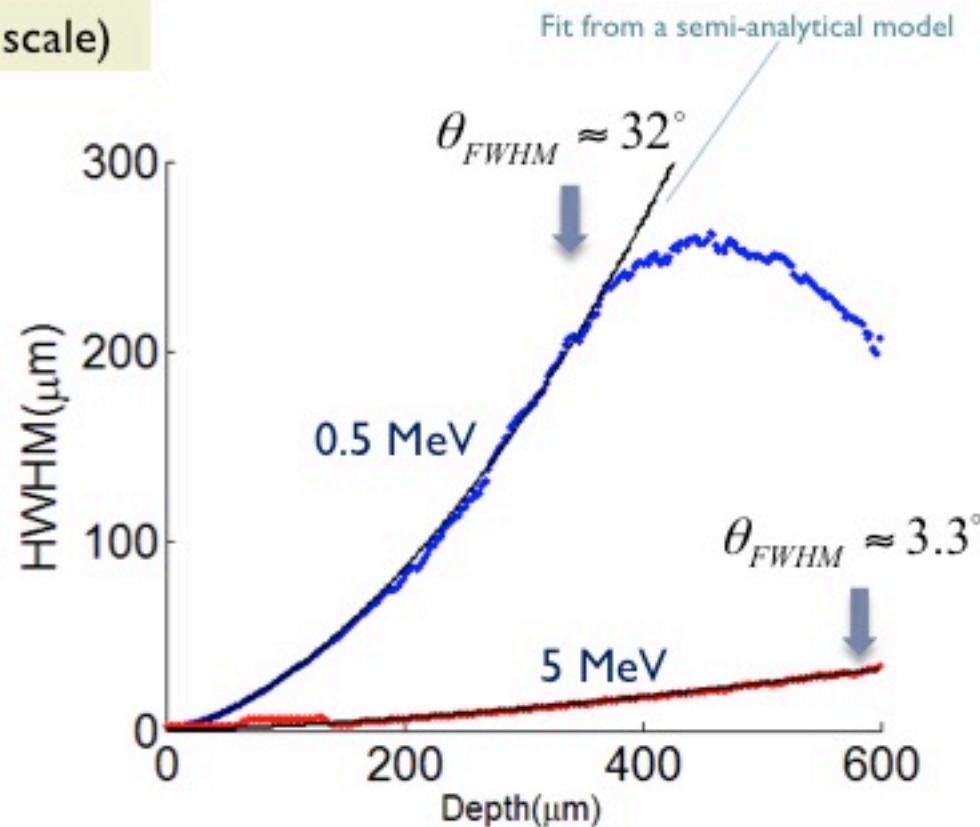
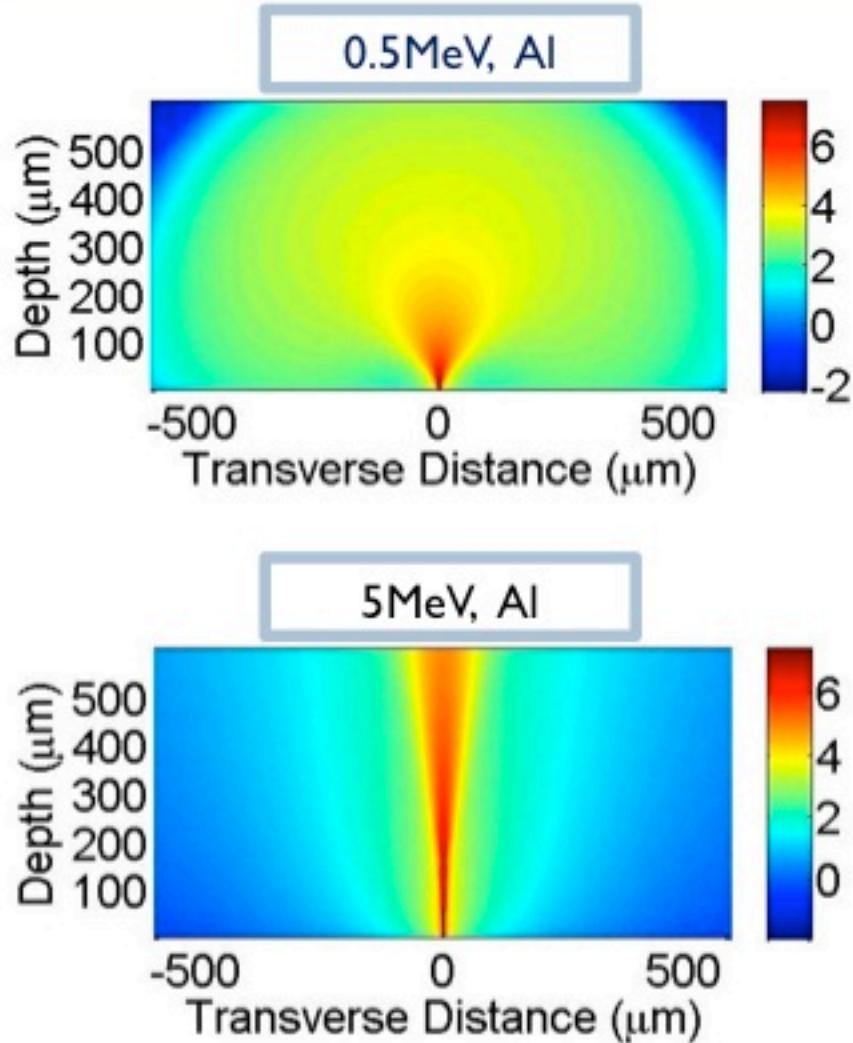
- ▶ e-i collision, photon and secondary e^- production
- ▶ No interaction between primary electrons.
- ▶ No external field



* D.B.Pelowitz etc. MCNPX User's manual, Version 2.5.0, LA-CP-05-0369 (2005).

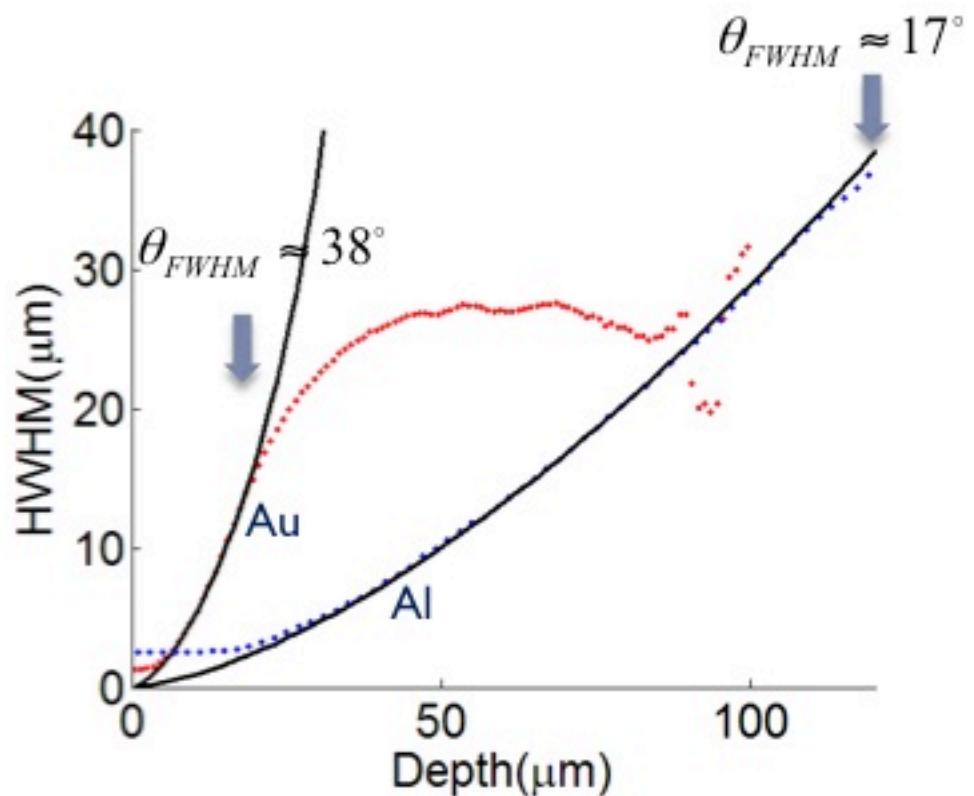
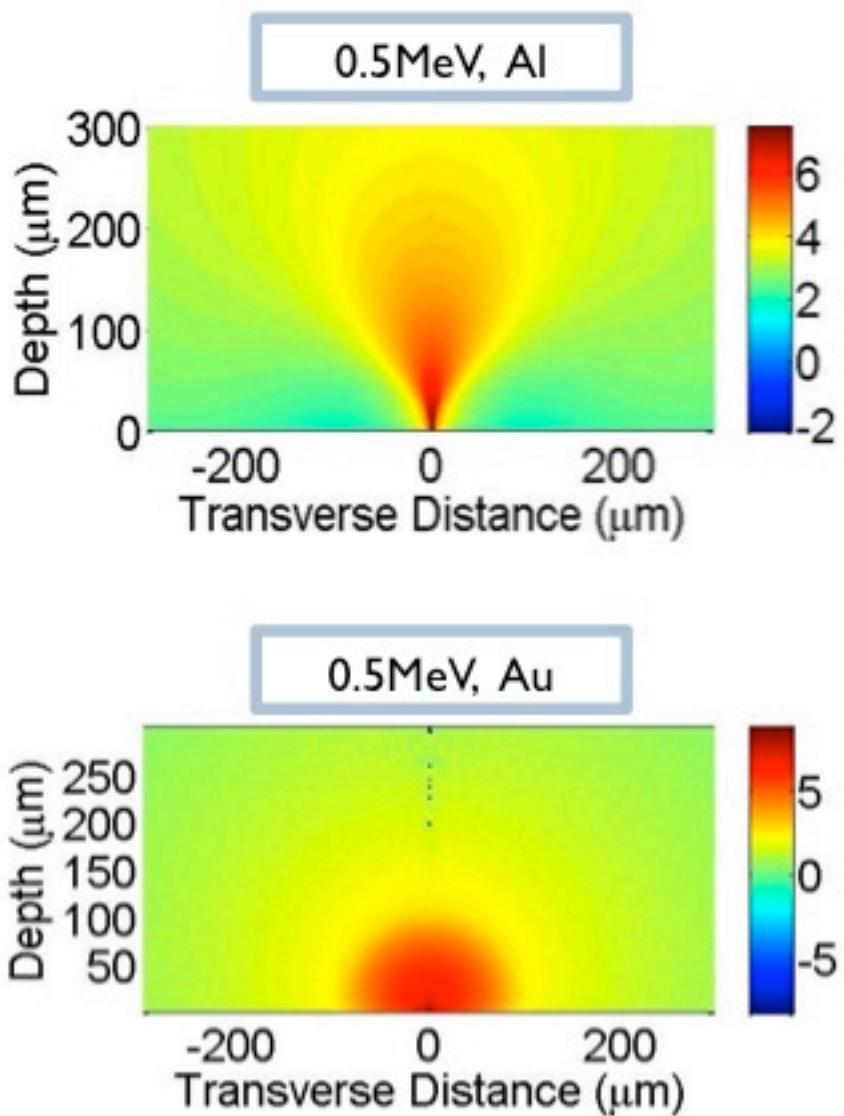
Simulations of Scattering of 0.5MeV and 5MeV Electrons in Al Target

Energy Deposition Density [MeV/cm³] (Log scale)



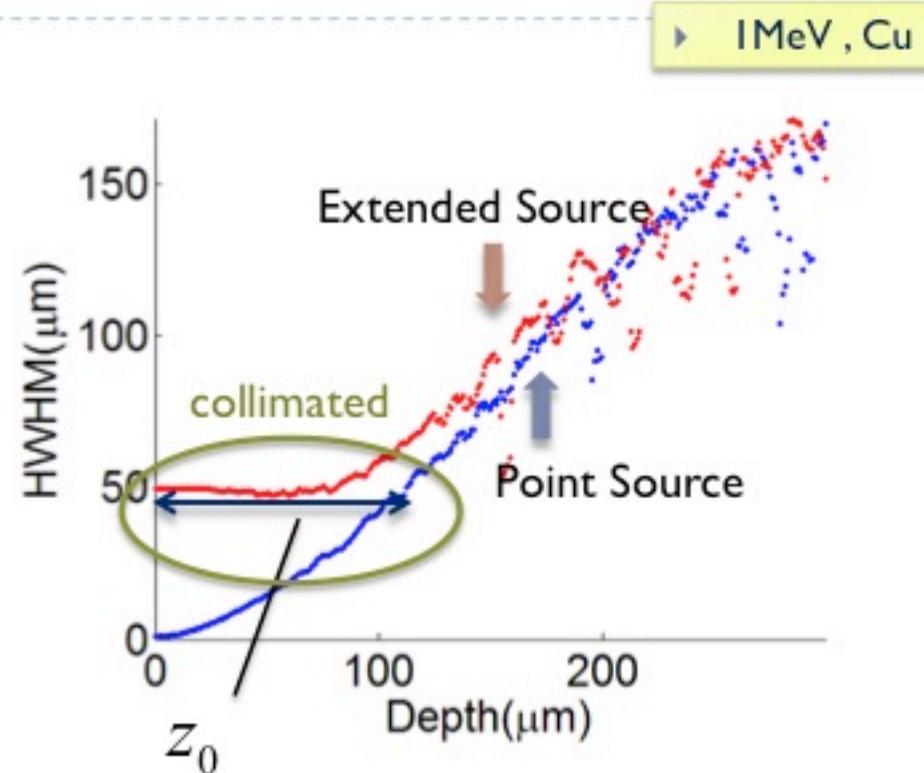
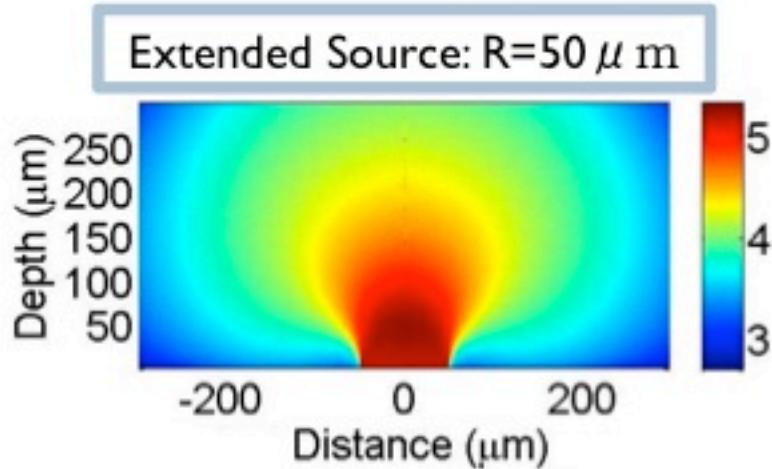
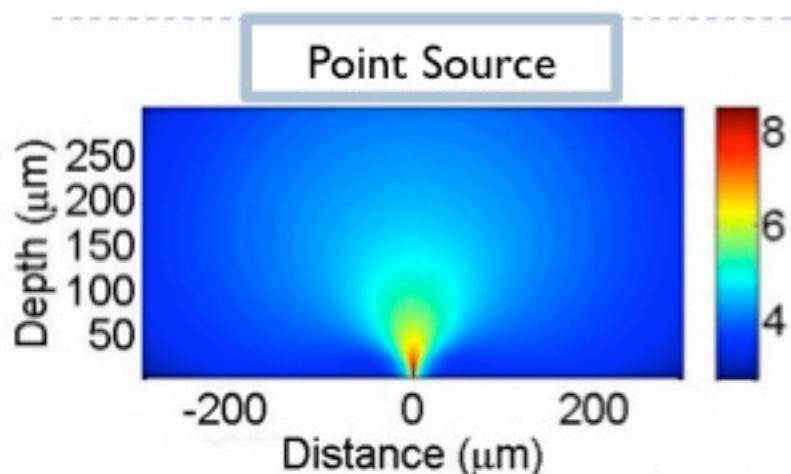
Scattering is more important for 0.5MeV electrons than 5MeV electrons.

Simulations of Scattering of Mono-Energetic Electrons in Low Z and High Z Targets



The higher the Z, the more important scattering is.

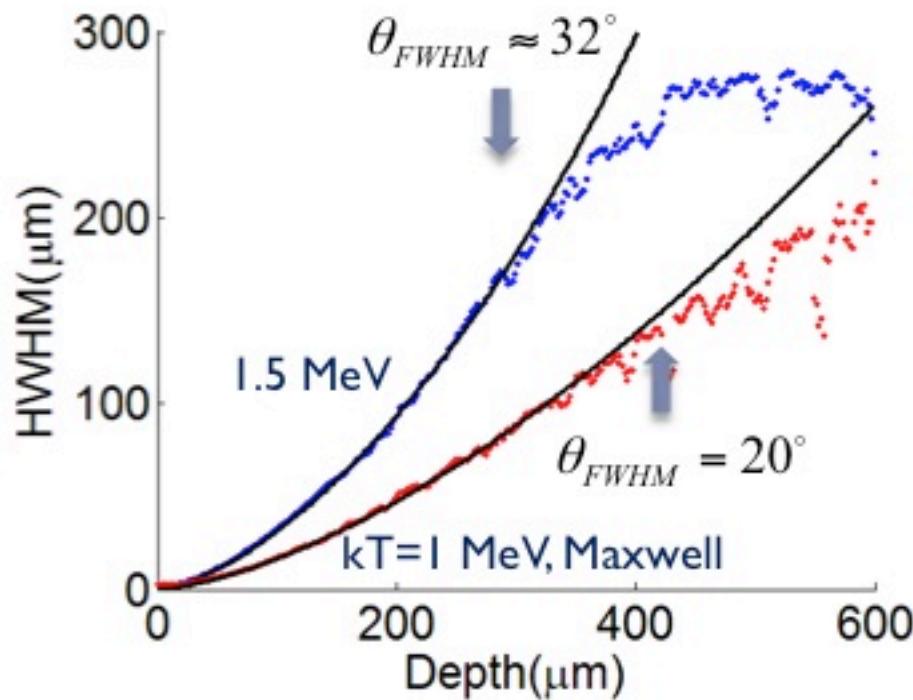
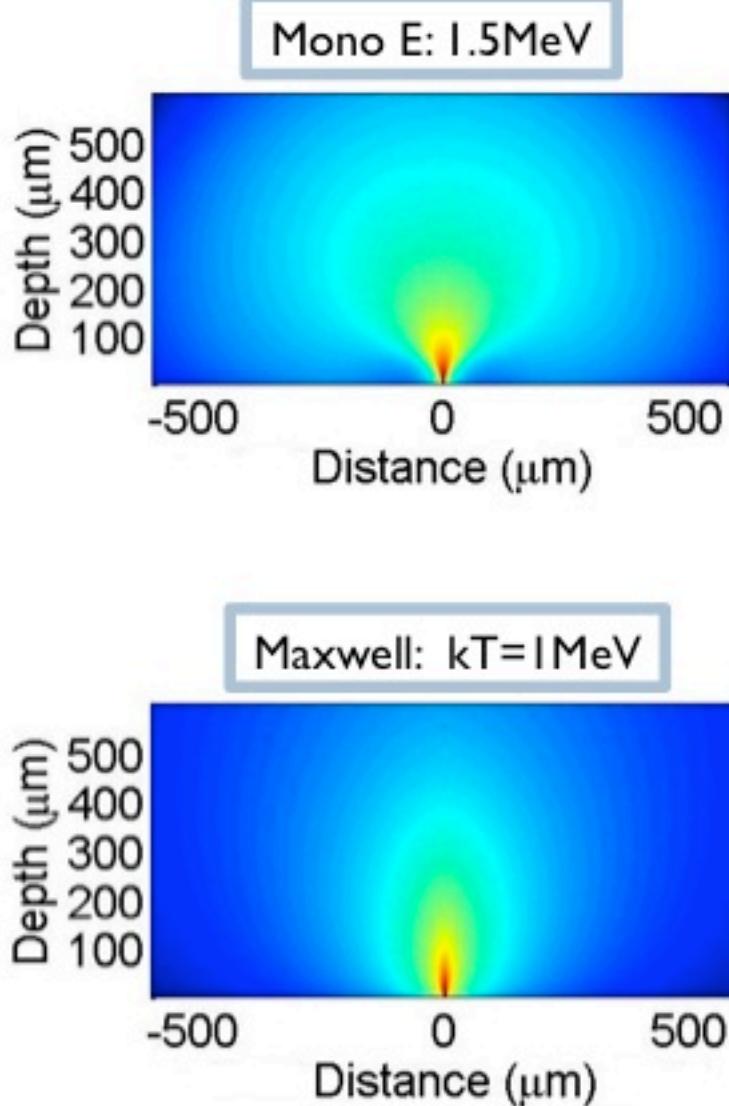
How Does The Source Size Affect Electron Beam Divergence?



$$Z_0 \propto \frac{r_0^{2/3} E^{2/3} A^{1/3}}{Z^{2/3} \rho^{1/3}}$$

- ▶ Divergence is evident for point source.
- ▶ Initial beam size can mask the divergence effect .
- ▶ Beyond a certain depth, we see same divergence due to scattering in both cases.

Maxwell Electron Energy Distribution Vs. Mono-Energetic Electrons



Divergence is lower for electron beams with a Maxwell distribution than mono-energetic electrons.

Divergence Simulations with a 3D Source Based on Laser Profile and PIC Simulations

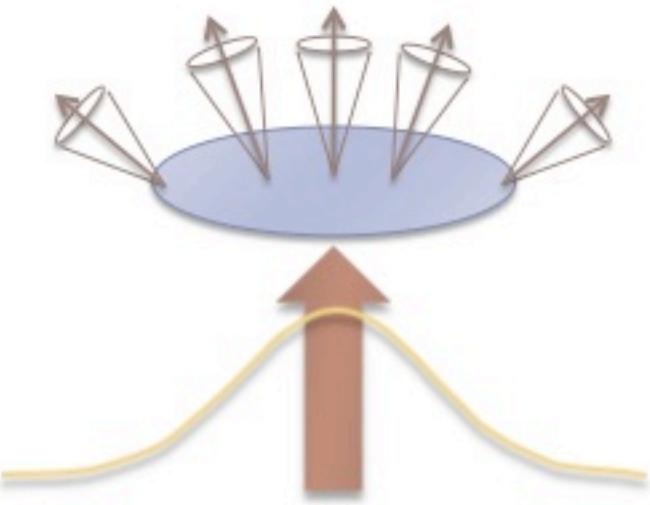
Source Electron Distribution

Position Direction

$$\frac{d^3 f(r, \psi, E, \theta, \varphi)}{dS dE d\Omega} = \underbrace{n(r)}_{I} \bullet \underbrace{F_1(E)}_{II} \bullet \underbrace{F_2(\theta, \varphi)}_{III}$$

$$I = A \exp\left(-\frac{2r^2}{w_0^2}\right)$$

$$II = 2\sqrt{\frac{E}{\pi}} \exp(-E/kT(r)), \quad kT = 0.511 \left(\sqrt{1 + \frac{I_0 \exp(-2r^2/w_0^2) \lambda_v^2}{1.37 \times 10^{18} W \mu m^2 / cm^2}} - 1 \right) MeV^{**}$$



Wilks Scaling **

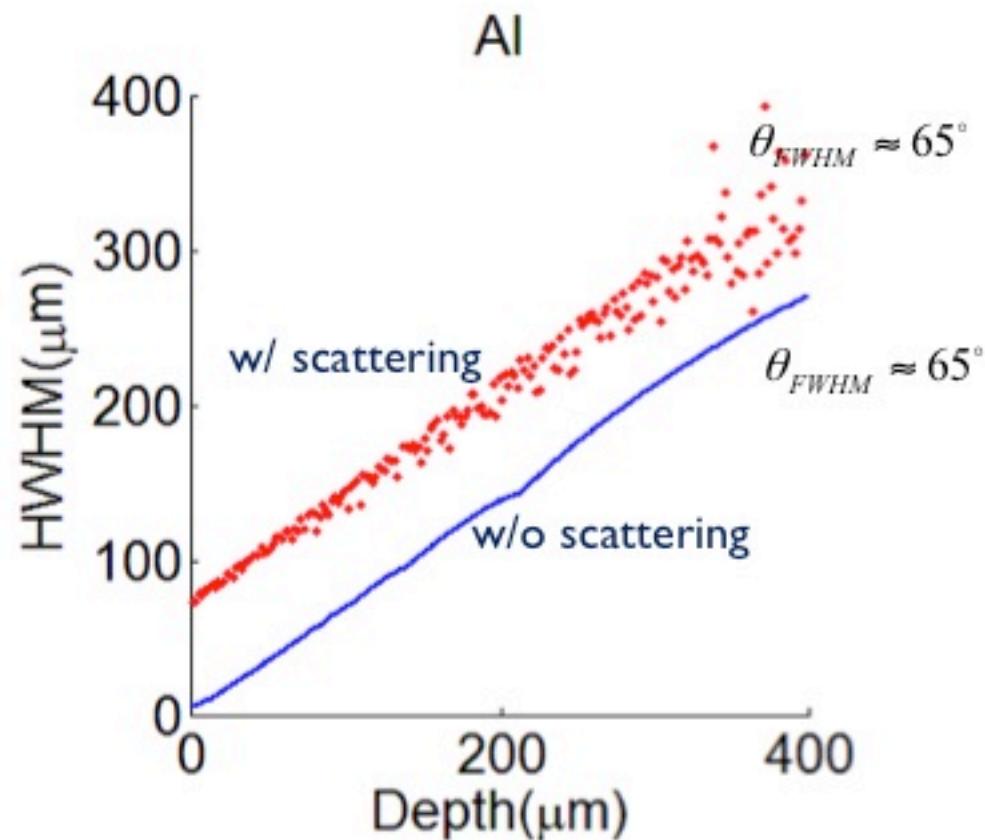
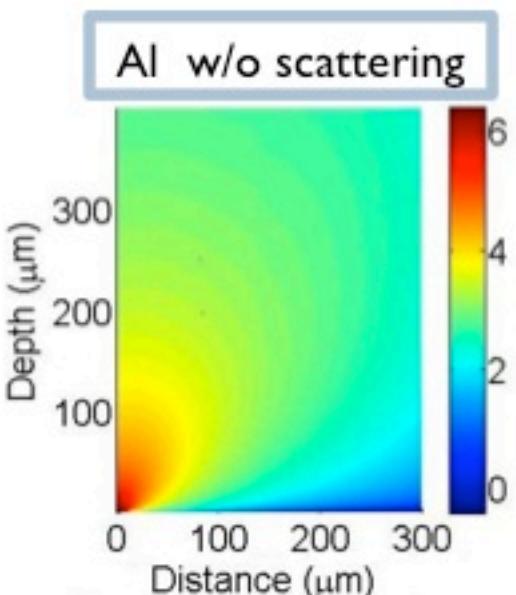
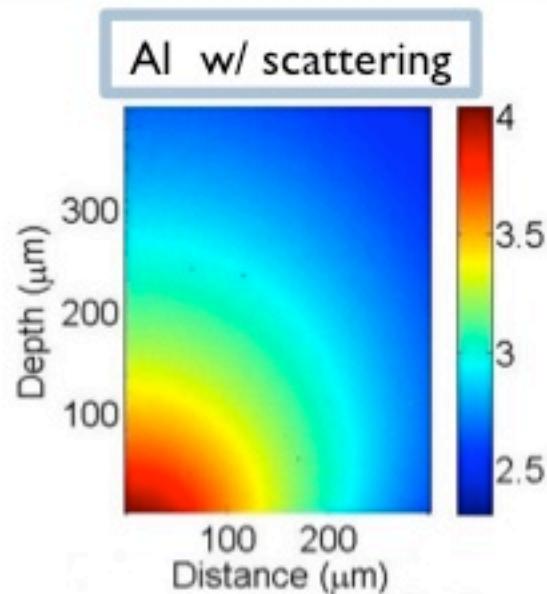
$$III = B \exp\left(-\frac{(\cos^{-1}(\sin \theta \sin \theta_r \cos \varphi \cos \psi + \sin \theta \sin \theta_r \sin \varphi \sin \psi + \cos \theta \cos \theta_r))^2}{\Delta \theta_0^2}\right)$$

Debayle & Honrubia Source Divergence *

* A. Debayle, J. J. Honrubia, E. d'Humières, V.T. Tikhonchuk Phys. Rev. E 82, 036405 (2010)

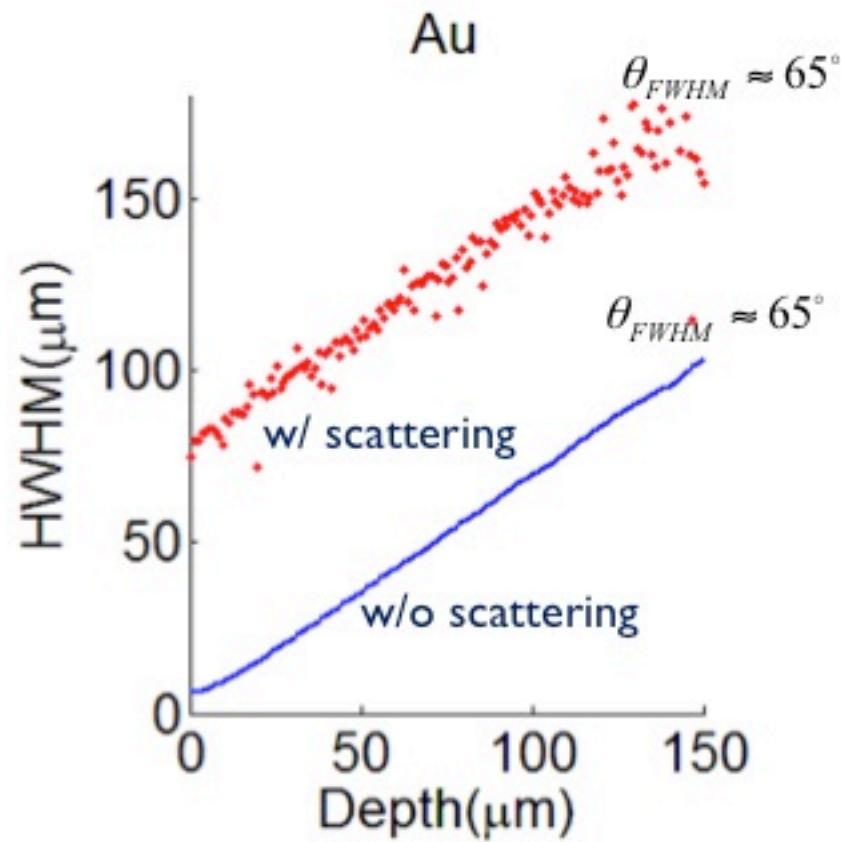
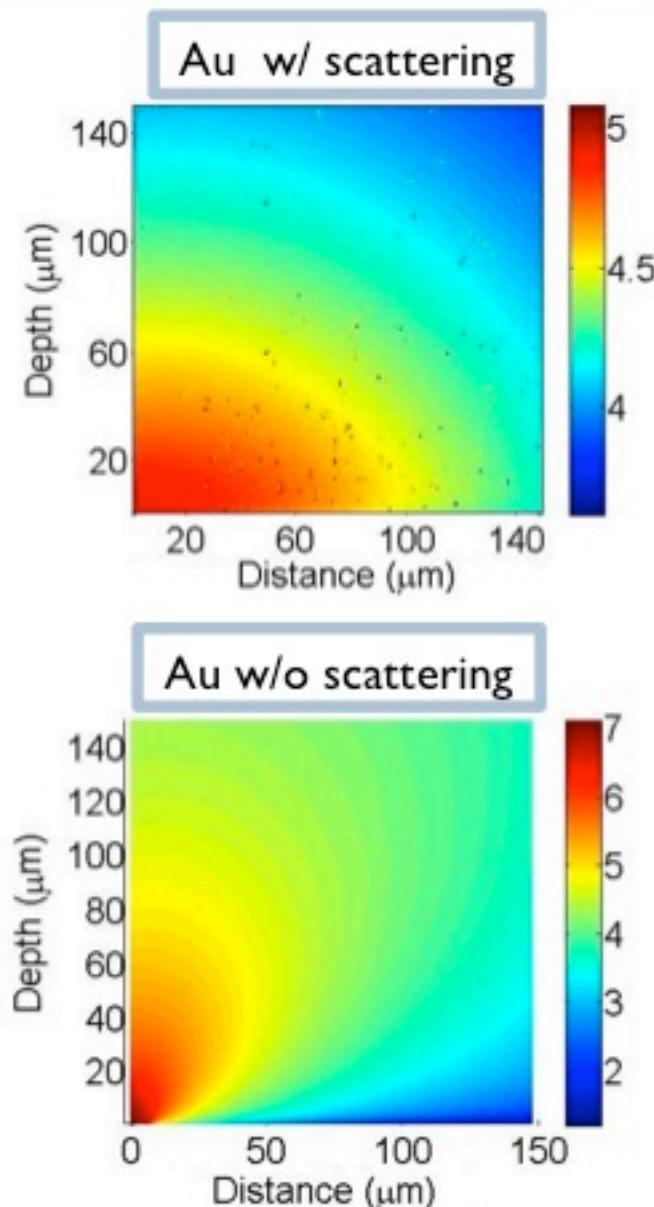
** S.C. Wilks, W.L. Kruer, M. Tabak, A.B. Langdon Phys. Rev. Lett. 69, 1383 (1992)

Electron Beam Divergence Simulation in Low Z Material with and without Scattering



HWHM at a given depth changes with and without scattering, however, divergence does not.

Electron Beam Divergence Simulation in High Z Material with and without Scattering



Same effects in high Z as in low Z material.

Conclusion

- ▶ Scattering influences the divergence of the beam:
 - ▶ Low energy electrons
 - ▶ High Z material
 - ▶ Thick Target
- ▶ Beyond a certain depth, beam divergence due to scattering is seen for both point and extended sources.
- ▶ Divergence is lower for electrons with a Maxwell distribution than those with a mono energy.
- ▶ With a laser based source:
 - ▶ Local beam size changes but divergence is the same
 - ▶ Same is true independent of Z

Acknowledgements



DEPARTMENT OF
PHYSICS

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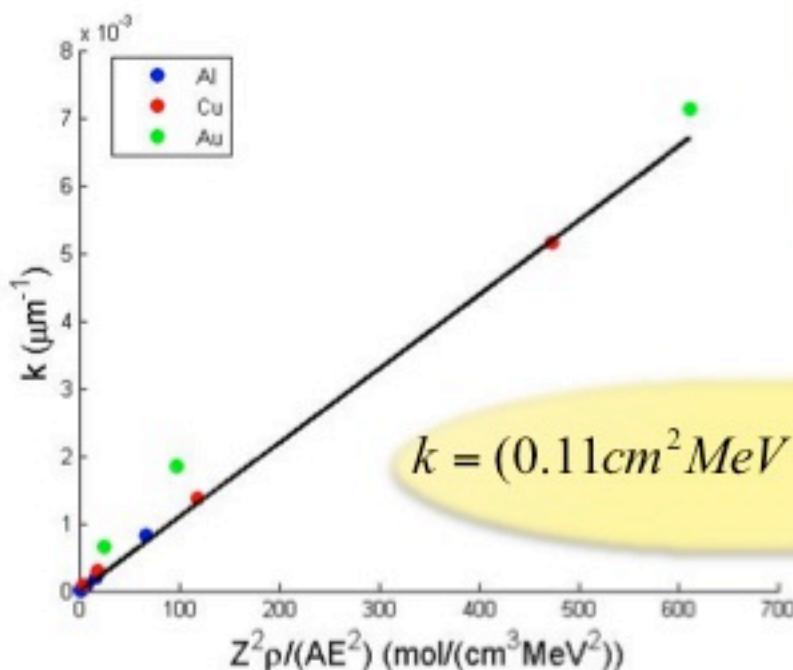
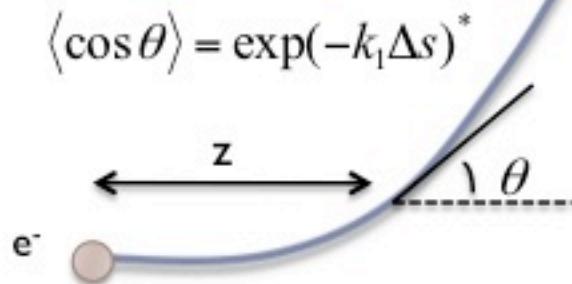
HEDP Group <http://www.hedp.osu.edu/>

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Scattering Effect Estimation

average e⁻ trajectory



Lower Z, higher E, smaller depth

Assume HWHM follows the same shape.

$$HWHM = z \frac{(kz - 2) + 2\sqrt{2/kz - 1} \tanh^{-1}(\frac{1}{\sqrt{2/kz - 1}})}{kz\sqrt{2/kz - 1}}$$

For $kz \ll 1$,

$$HWHM = \frac{1}{3} \sqrt{2k} z^{3/2}, \theta_{FWHM} \approx \frac{2}{3} \sqrt{2kz}$$

$$\text{To see the scattering effect: } \frac{2\sqrt{2C}}{3} \frac{Z}{E} \sqrt{\frac{\rho t}{A}} > \theta_{min}$$

Assuming $\theta_{min} = 5^\circ$

For $500 \mu\text{m}$ Al,

To see scattering : $E < 3.5 \text{ MeV}$

For $400 \mu\text{m}$ Cu,

To see scattering : $E < 7.8 \text{ MeV}$